

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: Masaya OGURA et al.				Eva		T	意思语
				Examiner: H. Nguyen Group Art Unit: 2851			12 12 12 12 12 12 12 12 12 12 12 12 12 1
Application No.: 09/811,419							CELVE TEN 2800 OCT 22 TENTER 2800
Filed: March 20, 2001						,800 (008,	
For: EXPOSURE APPARATUS, METHOD OF MANUFACTURING SEMICONDUCTOR DEVICES AND PLANT THEREFOR				Octo	ober 17, 200	02	
Commissione Washington,	er for Patents '. D.C. 20231		,				
Sir:							
X No	nerewith is an Am additional fee is re	equired.		ified ap	pplication.		
			CLAIMS AS AM	ENDED	· · · · · · · · · · · · · · · · · · ·		
	CLAIMS REMAINING AFTER AMENDMENT		HIGHEST NO. PREVIOUSLY PAID FOR	P	RESENT EXTRA	RATE	ADDITIONAL FEE
TOTAL CLAIMS	15	MINUS	20	=	0	x \$9 \$18	\$0.00
INDEP. CLAIMS	3	MINUS	3	=	0	x \$42 \$84	\$ 0.00
Fee for Multip	le Dependent claims	\$140/\$280				<u> </u>	
			TOTAL ADDITION FOR THIS AMEN				\$0.00

°Verified Statement claiming small entity status is enclosed, if not filed previously.

	A check in the amount of \$ is enclosed including the add	litional claims fee.			
	Charge \$ to Deposit Account No. 06-1205. A duplicate of this she	et is enclosed.			
X	Any prior general authorization to charge an issue fee under 37 CFR 1. 06-1205 is hereby revoked. The Commissioner is hereby authorized to under 37 CFR 1.16 and 1.17 which may be required during the entire per or to credit any overpayment, to Deposit Account No. 06-1205. A duple enclosed.	charge any additional fees endency of this application.			
X	A check in the amount of \$400.00 to cover the fee for a two month exte	nsion is enclosed.			
	A check in the amount of \$ to cover the Information Disclosure Sta	tement fee is enclosed.			
X	Applicants' undersigned attorney may be reached in our Washington, D.C. office by telephone (202) 530-1010. All correspondence should be directed to our address given below.				
	Respectfully submitted,				
	Attorney for Applicants Steven E. Warner Registration No. 33,326				

FITZPATRICK, CELLA, HARPER & SCINTO 30 Rockefeller Plaza
New York, New York 10112-3801
Facsimile: (212) 218-2200

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00862.022151.	PATENT APPLICATION
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Masaya OGURA et al.	Examiner: H. Nguyen
Application No.: 09/811,419	Examiner: H. Nguyen Group Art Unit: 2851
Filed: March 20, 2001	:)
For: EXPOSURE APPARATUS, METHOD OF MANUFACTURING SEMICONDUCTOR DEVICES AND PLANT THEREFOR	: October 17, 2002 :)
The Commissioner for Patents	

AMENDMENT WITH PETITION FOR EXTENSION OF TIME

Sir:

Washington, D.C. 20231

Applicants petition the Commissioner for Patents to extend the time for response to the Office Action dated May 17, 2002, for two months from August 17, 2002, to October 17, 2002. A check in the amount of \$400.00 for payment of the extension fee is enclosed. Please charge any additional fee required for the extension, or credit any overpayment, to Deposit Account 06-1205.

In response to the Official Action dated May 17, 2002, please amend the above-identified application as follows:

10/21/2002 AUSMAN1 00000071 09811419 400.00 OP 01 FC:1252